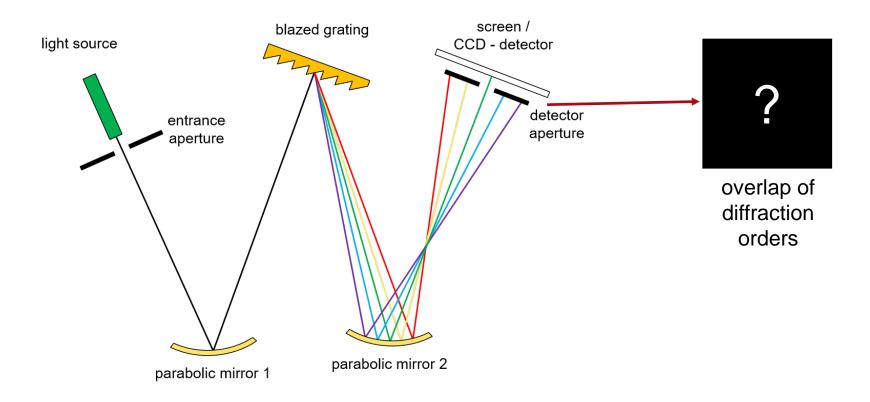


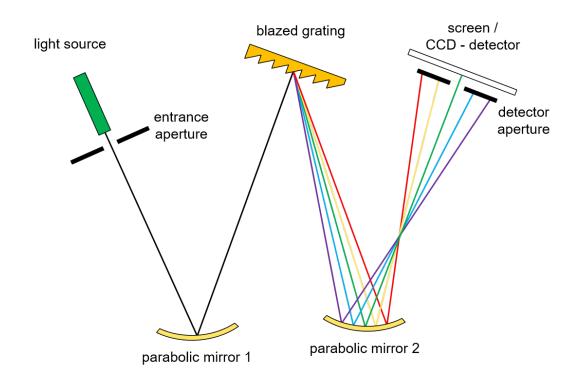
Optical Metrology > Monochromator

# Czerny-Turner Monochromator – Overlap of Diffraction Orders

# **Task/System Illustration**

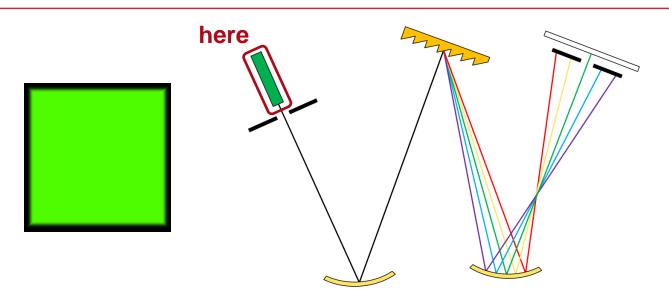


#### **Highlights**



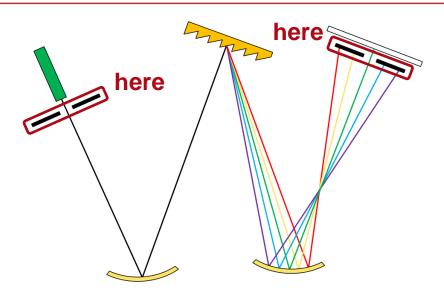
- high-performance analysis of complex optical systems
- full vectorial analysis of gratings by using rigorous algorithm (FMM)

# **Specification: Light Source**



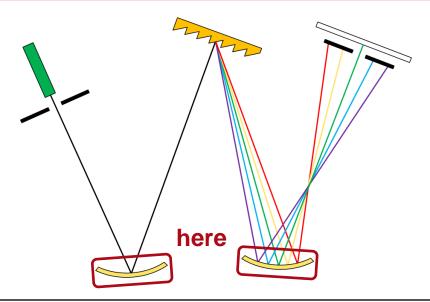
Parameter	Description / Value & Unit
type	plane wave
wavelengths	380nm, 760.2nm
polarization	linear in x-direction (0°)

### **Specification: Apertures**



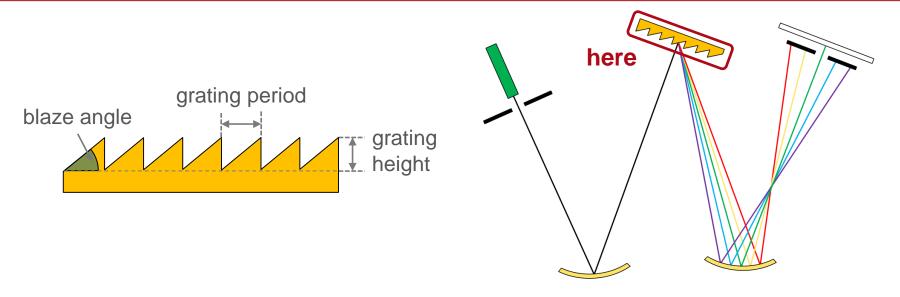
Parameter	Description / Value & Unit
width of entrance aperture	500 µm
width of detector aperture	649µm

#### **Specification: Parabolic Mirrors**



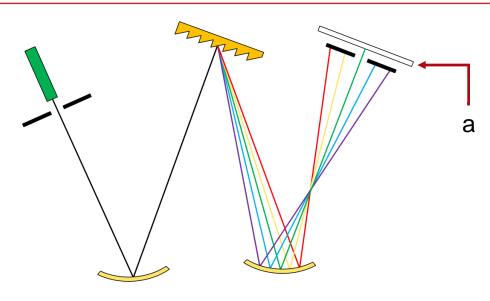
Parameter	Description / Value & Unit
type	parabolic mirror
material	ideal high-reflective material
focal length	1 m
diameter	20mm
tilt angle	5°
reflectance	100%

### **Specification: Grating**



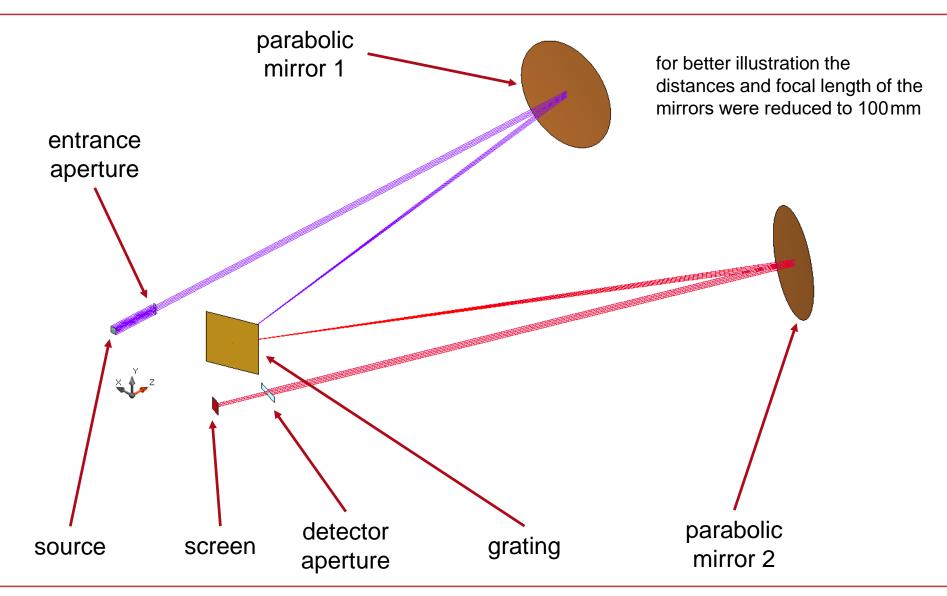
Parameter	Description / Value & Unit
grating period	833 nm
grating height	282.4 nm (optimized for -1st order efficiency)
propagating orders	1 <sup>st</sup> and 2 <sup>nd</sup>
blaze angle	18.7°
grating material	silver (Ag)
substrate material	silver (Ag)

# **Specification: Detectors**



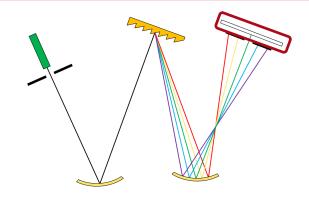
Position	Modeling Technique	Detector/Analyzer
full system	3D ray tracing	3D ray tracing system visualization
а	field tracing	2D intensity (real color view)

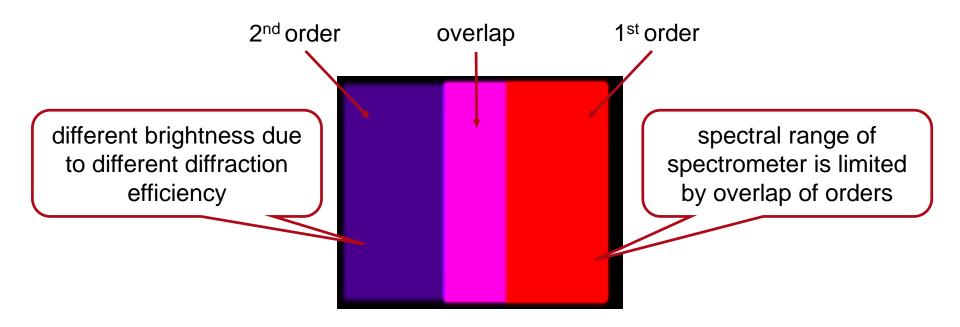
#### **Result: 3D Ray Tracing**



#### **Result: Field Tracing**

overlap of 1<sup>st</sup> diffraction order @760nm and 2<sup>nd</sup> order @380nm on detector





#### **Document & Technical Info**

code	MONO.0003
version of document	1.0
title	Czerny-Turner Monochromator – Overlap of Diffraction Orders
category	Optical Metrology > Monochromator
created by	Rui Shi (LightTrans)
used VL version	7.0.0.29

Specifications of PC Used for Simulation		
Processor	i7-4700MQ (1 CPU cores)	
RAM	16 GB	

Operating System Windows 8